

# ECLIPSE L300N/L300ND L200N/L200ND

Microscopes for Flat Planel Display and Large Scale Integration Inspection







L300N For ø300 mm wafer/ **Episcopic optical contrast** 



\_300ND For 17-inch FPD/ **Episcopic and Diascopic optical contrast** 



L200N For ø200 mm wafer/ **Episcopic optical contrast** 

# Enhanced observation performance and operation

#### Epi-fluorescence observation widens inspection range-including 365 nm UV excitation

\*L300N/L300ND/L200ND only

- Highly beneficial when inspecting semiconductor resist residues and organic electroluminescence displays.
- Various observation methods such as brightfield, darkfield, simple polarizing, and DIC are possible on all models.
- With the L300ND/L200ND, diascopic illumination capability adds the illumination through transparent substrates.



of wafer pattern





DIC observation



Epi-fluorescence observation of organic substance on wafer

#### Target for easier focusing

• Insert a focusing target in the optical path to easily focus on low-contrast samples, such as bare wafers.



#### Stronger safeguard against contamination

- Antistatic coatings applied to the body, stage, eyepiece tube and other various controls
- Prevents damage to samples and contributes to higher yields

#### Observation at optimum eyepoint level

• Ultra-wide 25-mm field of view and evepiece angle adjustment between 0 ° and 30 °

 Operators can adjust evepoint level to ensure a comfortable viewing position



#### Fixed-position X-Y fine movement control

 Allows for stage movements and focusing to be carried out with ease



positioned close to the operator.

Front operation with easy access

 Minimizes fatigue during lengthy observations, maintaining a safer operator distance from the sample







# Illumination

#### LED

Compact LED illuminators are power saving and achieve long life.



LV-LL LED Lamphouse

#### Intensilight

• Motorized mercury precentered fiber illuminator for epi-fluorescence observation, with variable light intensity and shutter control, provide excellent flexibility. Lamp centering and focus adjustment are not necessary.

#### Filter blocks

For epi-fluorescence observation

- EPI-FL UV-2A
- EPI-FL V-2A
- EPI-FL BV-2A



\*Only one cube is attachable

# Accessories

Nikon's CFI60 optical systems are highly evaluated for their unique concept of high NA combined with a long working distance. These lenses have been developed further and evolved achieving the apex in long working distance specifications, correct chromatic aberration, and an optimized lens weight.

#### Objective lenses

**Standard objective lenses** TU Plan Fluor Series EPI/BD 5x/10x/20x/50x/100x

Enable brightfield, darkfield, simple polarizing, sensitive polarizing, differential interference, and epi-fluorescence observations with just one lens. Achieves superior chromatic aberration performance with long working distance for all magnifications to adapt to any application



\*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan Fluor EPI	5×	0.15	23.5
(brightfield type)	10×	0.30	17.5
	20×	0.45	4.5
	50×	0.80	1.0
	100×	0.90	1.0
TU Plan Fluor BD	5×	0.15	18.0
(brightfield/ darkfield type)	10×	0.30	15.0
	20×	0.45	4.5
	50×	0.80	1.0
	100×	0.90	1.0

#### Long working distance objective lenses



With the phase Fresnel lenses, these objective lenses

enable long working distances while offering higher level chromatic aberration correction than conventional objective lenses. This improves operability for samples with different heights.

Nikon	Nikon	Nikon
U Plan ELWD	TU Plan ELWD	TU Plan ELW
20x/0.40 s	50×/0.60 .	100x/0.80 s
OFN25 WD 18	0/N25 WD.11	OFNES WD 45

\*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan EPI ELWD	20×	0.4	19.0
(brightfield type)	50×	0.6	11.0
	100×	0.8	4.5
TU Plan BD ELWD	20×	0.4	19.0
(brightfield/ darkfield type)	50×	0.6	11.0
	100×	0.8	4.5

# Low-magnification objective lenses

T Plan EPI EPI 1x/2.5x

Model	Magnification	NA	Working Distance (mm)
T Plan EPI	1×	0.03	3.8
(brightfield type)	2.5×	0.075	6.5

#### **Apochromatic objective lenses**

TU Plan Apo Series EPI/BD 50x/100x/150x



Wide field of view

By using phase Fresnel lenses, these objective lenses

achieve significantly longer operating distances while maintaining the superior chromatic aberration performance of apochromatic lenses.



\*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan Apo EPI	50×	0.8	2.0
(brightfield type)	100×	0.9	2.0
	150×	0.9	1.5
TU Plan Apo BD	50×	0.8	2.0
(brightfield/ darkfield type)	100×	0.9	2.0
	150×	0.9	1.5

#### Other lenses

Lenses with correction mechanism

CFI L Plan EPI CR Series EPI 20x/50x/100x



Model	Magnification	NA	Working Distance (mm)	Glass Thickness Correction Range (mm)
CFI L Plan EPI CR	20×	0.45	10.9-10.0	0-1.2
CFI L Plan EPI CR	50×	0.7	3.9-3.0	0-1.2
CFI L Plan EPI CRA	100×	0.85	1.2-0.85	0-0.7
CFI L Plan EPI CRB	100×	0.85	1.3-0.95	0.6-1.3

#### Microscope camera

### **Digital Sight 1000**

Equipped with a 2 megapixel CMOS image sensor, it can capture full HD microscope images. By connecting a microscope to this camera and HDMI monitor, movies and images can be captured and saved onto a pre-inserted SD card in the camera.





DS-Fi3

rame Rate	30 fps (1920×1080)	30 fps (144
ax Recordable Pixels	1920×1080	2880×

#### Imaging software NIS-Elements





Simply installing NIS-Elements L

on a tablet PC enables setting and

control of Digital Sight 1000/DS-Fi3/Digital Sight 10 microscope cameras, live image display, and image acquisition.

#### A wide variety of tools

NIS-Elements L enables the conducting of simple measurements on images, with input of lines and comments. These can also be written onto and saved with the image, and measurement data can be output

Measurement function	ion			¥
Line distance	Circle distance	-		4
🕗 Area	Pitch distance			
Circle	Angle		Length= 6168.28 µm	
Annotate function				×
🖊 Line	😳 Marker			1
Arrow	Polyline	. <b>↑</b>		
A Text				
Line		, À		

#### **Scene Mode**

Ten camera setting patterns for optimal color reproduction and contrast for each microscope light source, observation method and type of sample, as well as custom settings, can be selected.

Wafer/IC	Metal, Ceramic/Plastic
<ul> <li>Circuit board</li> </ul>	<ul> <li>Flat Panel Display</li> </ul>

\* See the "Digital Camera Digital Sight Series for Microscopes" catalog for details on Digital Sight features.

Three main features of the previous models, high-resolution, high sensitivity and low noise, and high-speed live display are offered in 1 camera.

## **Digital Sight 10**

This high-resolution camera captures both color and monochromatic images at up to 6,000 x 3,984 pixels. This enables the wide range of images to be captured and then many of them to be stitched together making a single and large combined image.



40×1024) 66 fps (1920×1080) <2048 6000×3984





#### Image Stitching

Stitches together images acquired from multiple fields of view to create one image.







#### EDF (Extended Depth of Focus)

Create a single, all-in-focus image from images of differing focus.





# Wafer loader NWL200

Combined with the NWL200 wafer loader, the ECLIPSE L200N meets requirements for wafer inspections.

#### Support for ultra-thin 100 µm wafers

• NWL200 series provides levels of safety and reliability that meet all requirements for inspection of the latest wafers.

#### Improved operability and high throughput

• Setting conditions, such as sampling and inspection patterns, and checking the operating status and content of errors can easily be done with the large LCD panel

- Comprehensive file management functions for carriers and samples are useful for automating inspections
- Exceptionally fast elevator, and the loading and unloading of wafers with complete precision by the multi-arm system all contribute to an efficient wafer transfer and exchange

# Dimensional diagram (Unit: mm)





#### ECLIPSE L200N/L200ND





# System diagram

ECLIPSE L300N/L300ND





\*1 Diascopic illumination available only for L300ND and L200ND \*2 Epi-fluorescence observation available only for L300ND/L300N/L200ND

# **Specifications**

		ECLIPSE L300N	ECLIPSE L200N	ECLIPSE L300ND	ECLIPSE L200ND	
Illumination type		Episcopic Episcopic/Diascopic			/Diascopic	
Main body		Power sources for motorized control built in Motorized control for nosepiece, Light intensity control, Aperture diaphragm control				
Nosepiece		Motorized universal sextuple nosepiece				
	Centering Function	Yes		Yes	_	
	EPI/DIA changeover	—	_	Y	es	
Focusing mechanism	Cross travel	29 mm				
	Coarse	12.7 mm per rotation (tor	que adjustable, refocusin	g mechanism provided)		
	Fine	0.1 mm per rotation (in 1 µm increments)				
Episcopic illuminator		12V-50W halogen lamp light source built in, LV-LL LED Lamphouse Motorized aperture diaphragm (centerable), Fixed field diaphragm (with focus target) Pinhole slider (optional), Four ø25 mm filters (NCB11, ND16, ND4), Polarizer and Analyzer can be mounted Observation methods: Brightfield, Darkfield, Simple polarizing, DIC, Epi-fluorescence* (*L300N/L300ND/L200ND only)				
Diascopic illuminator						
Interface		USB x 1, RS232C (for Intensilight) x 1				
Eyepiece tubes		L2-TT2A Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/20:80 L2-TTA Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/0:100 LV-TI3 Trinocular eyepiece tube (erect image) FOV: 22/25; Beam split ratio 100:0/0:100				
Eyepieces		CFI eyepiece lens series	· · · · ·			
Objective lenses		CFI60-2/CFI60 system				
Stages		L3-S12 14 x 12 stage	L2-S8A 8 x 8 stage	L3-S12 14 x 12 stage	L2-S8A 8 x 8 stage	
	Stroke	354 x 302 mm	205 x 205 mm	354 x 302 mm	205 x 205 mm	
	Diascopic observation range	354 x 268 mm	150 x 150 mm	354 x 268 mm	150 x 150 mm	
		Coarse/Fine-movement	changeover possible Fixe	d-position X-Y fine-moven	nent controls	
Antistatic mechanism		1000-10 V, within 0.2 sec	>			
Power consumption		1.2 A/90 W				
Weight (approx.)	Body only	38 kg	31 kg	40 kg	31 kg	
	With L2-S8A 8 x 8 stage and L2-TTA eyepiece tube	-	45 kg	-	44 kg	
	With L3-S12 14 x 12 stage and L2-TTA eyepiece tube	57 kg	-	59 kg	-	

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🔥 WARNING

TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING THE EQUIPMENT.



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